

AMENDMENTS TO THE SPECIFICATION:

Please replace the paragraph beginning at page 5, line 15, with the following rewritten paragraph:

--Highly preferred precursor source mixtures comprised of at least one alkyl-containing compound include: trimethyl-, triethyl-, triisobutyl-, tri-n-propyl-, triisopropyl-, tri-n-butyl-, trineopentyl-, or ethyldimethyl-B, Al, Ga, In, As or Sb; tetramethyl-, tetraethyl-, tetraphenyl-, or tetra-n-butyl-Si, Ge, Sn, or Pb; dimethyl-, diethyl-, or diisobutyl-B, Al, Ga, In, As or Sb, hydride, chloride, fluoride, bromide, iodide, Cp, amide, dimethylamide or azide; triethyl-, triisobutyl-, tri-n-propyl-, triisopropyl-, tri-n-butyl- or ethyldimethyl-B, Al, Ga, In, As or Sb trimethylamine, diethylmethylaniline, dimethylethylaniline, or triethylaniline; dimethyl- or diethyl-Zn, Cd, or Hg;(neopentyl)₄Cr; Et₃Pb(neopentoxo); Cp₂Me₂Zr; (MeNC)₂PtMe₂; or CpIr(C₂H₄)₂ where Cp is cyclopentadienyl or substituted cyclopentadienyl wherein replacement of H substituent(s) with methyl, ethyl, isopropyl, n-butyl, sec-butyl, tert-butyl, trimethylsilyl or other like substituents dissolved, emulsified or suspended in a C₅-C₁₂ alkane liquid. Other preferred precursor source mixtures are comprised of at least one alkyl-containing compound including, but not limited to: a trimethyl or triethyl substituent in emulsified or suspended in a liquid composed essentially of a C₅-C₁₂ alkane liquid with optionally added methane or ethane (no more than 30% by volume of the inert liquid).--